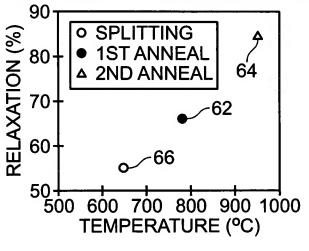
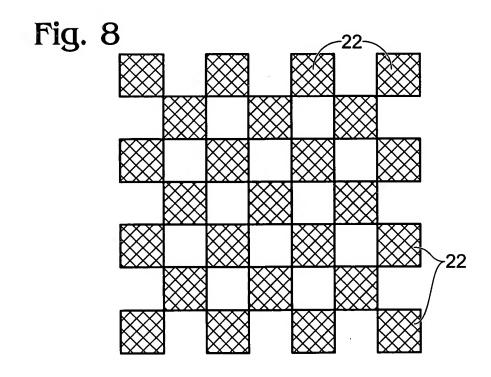


Fig. 7 RELAXATION OF SIGE ON SIO2 AFTER WAFER SPLITTING AND ANNEAL





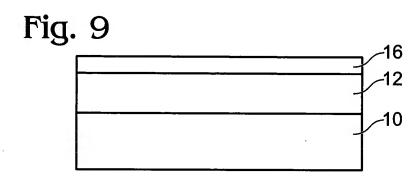
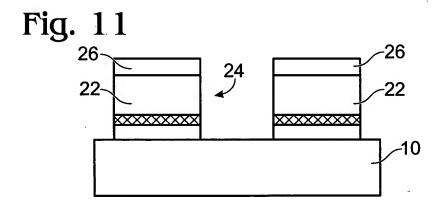


Fig. 10



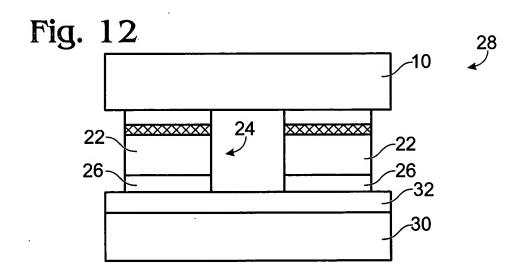


Fig. 13

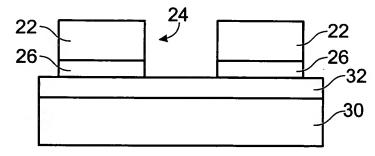


Fig. 14

